



UNIVERSITY OF WASHINGTON

BEE331 LAB 2.1

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# Characterising MOSFET; I-V Curve

## Design Objective

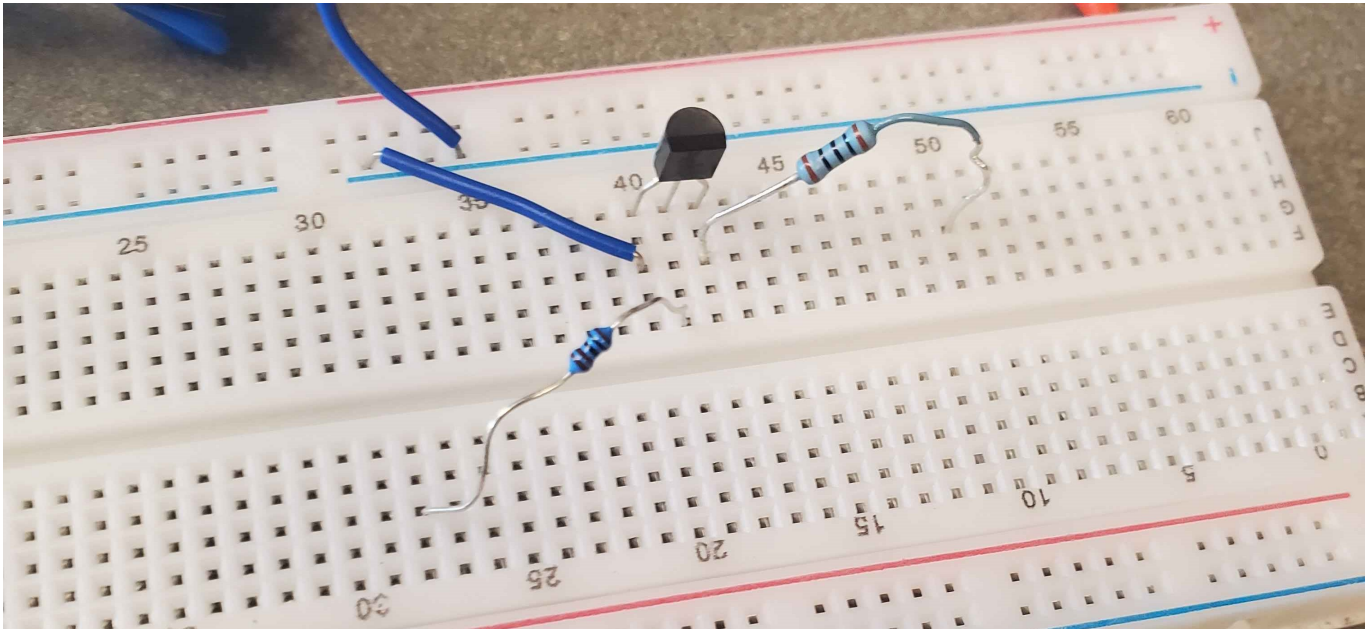
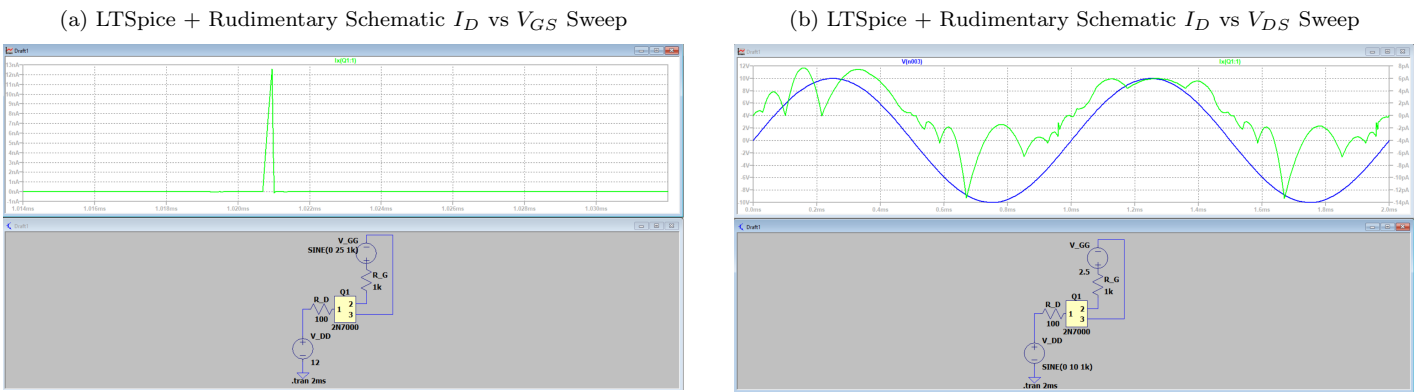
In this lab, we introduce ourselves to the MOSFET, we characterise its function  $V_{DS}$  and  $I_D$  curve; related to Triode, Threshold, and Saturation.

### Circuit Design Outline

With an NMOS (2N7000) Transistor in series from Voltage Input  $V_{DD} = 12V$  to a resistor ( $R_D = 100\Omega$ ), the voltage drop in  $V_{DS} = V_D - V_S$ , to ground. In the Gate  $V_G$  over the capacitor of the MOSFET; in series with a resistor ( $R_G = 1k\Omega$ ), being supplied with it's own voltage source;  $V_{GG}$ .

The demonstrated circuits below use a sinusoidal sweep with  $V_{DD}$  and  $V_{GG}$  respectively to demonstrate the  $I_D$  relation over a voltage-change.

Figure 1: 2N7000 NMOS



(c) 2N7000 NMOS Transistor MOSFET Circuit

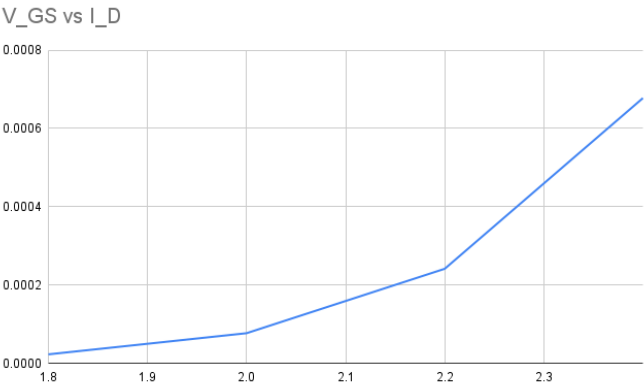
Descriptions of Measurements & Calculations

Analysis

- i. Use your plot (or data) to find the value of  $V_{GS}$  which just starts to produce a non-zero drain current. This is the threshold voltage  $V_t$  of the MOSFET under test.  
See below for tables and graphs of  $[I_D \text{ vs } V_{GS}]$ , and  $[I_D \text{ vs } V_{GS}]$ .
- ii. How close are the measured and calculated values of  $V_{DS}$  at the boundary of triode and saturation regions of the MOSFET?  
 $V_{GS} \text{ vs } I_D$ : From when the current has a measurable rating (1.8V), saturates at a 0.6V difference (2.4V).  
 $V_{DS} \text{ vs } I_D$ : From when the current plateaus at its greatest amount (1V to 1.5V), saturates at a .5V difference (@1.5V). Then proceeds to break the component's specifications by breaching current at around 5V
- What model parameters of the MOSFET would you adjust (and how) to match the experimental results?  
To simulate the  $I_D$  change over a voltage change for [Saturation] and [To 10V] respectively, we AC-swept over a region. Aside from the simulation-method, here is the Github link to the .lib model we used to simulate the 2N7000 component.
- Do the values of  $k_n$  obtained from measurements agree with  $k_n$  obtained from the model?  
Simply, yes; given  $k_n = (\frac{I_D * 2}{V_{RD} - 1.6})^2$

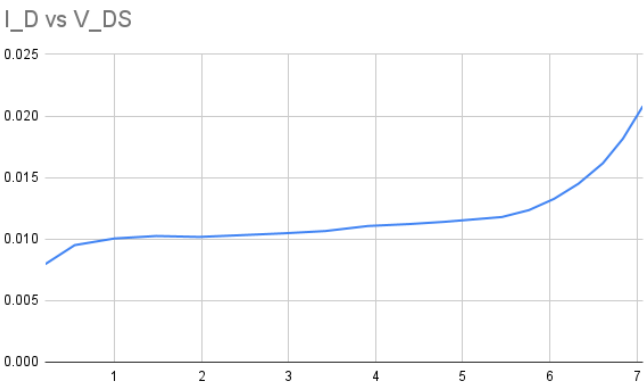
Figure 1: NMOS Circuits

(a)  $V_{GS}$  vs  $I_D$  Graph



(b) Lab 2 2-2A-I Table

VGS	V(RD)	ID	kn
0.2	0		
0.4	0		
0.6	0		
0.8	0		
1	0		
1.2	0		
1.4	0		
1.6	0.0002	0.000002	#DIV/0!
1.8	0.00228	0.0000228	0.00114
2	0.00768	0.0000768	0.00096
2.2	0.024139	0.00024139	0.001341055556
2.4	0.06775	0.0006775	0.0021171875



(c)  $I_D$  vs  $V_{DS}$

VDD	V(RD)	ID	VDS
1	0.7955	0.007955	0.2
1.5	0.9507	0.009507	0.54
2	1.005	0.01005	1
2.5	1.0248	0.010248	1.48
3	1.0172	0.010172	1.97
3.5	1.0314	0.010314	2.45
4	1.0465	0.010465	2.94
4.5	1.065	0.01065	3.42
5	1.106	0.01106	3.91
5.5	1.122	0.01122	4.39
6	1.14	0.0114	4.79
6.5	1.16	0.0116	5.13
7	1.179	0.01179	5.45
7.5	1.235	0.01235	5.76
8	1.327	0.01327	6.05
8.5	1.45	0.0145	6.33
9	1.616	0.01616	6.61
9.5	1.815	0.01815	6.84
10	2.08	0.0208	7.07

(d) Lab 2 2-2A-I Table

Figure 1: Jason Truong Addendum

(a) Lab Design Calculations

$$I_D = I_S (e^{qV_D / NkT} - 1)$$

Where,

$I_D$  = Diode current in amps

$I_S$  = Saturation current in amps  
(typically  $1 \times 10^{-12}$  amps)

$e$  = Euler's constant ( $\sim 2.718281828$ )

$q$  = charge of electron ( $1.6 \times 10^{-19}$  coulombs)

$V_D$  = Voltage applied across diode in volts

$N$  = "Nonideality" or "Emission" coefficient  
(typically between 1 and 2)

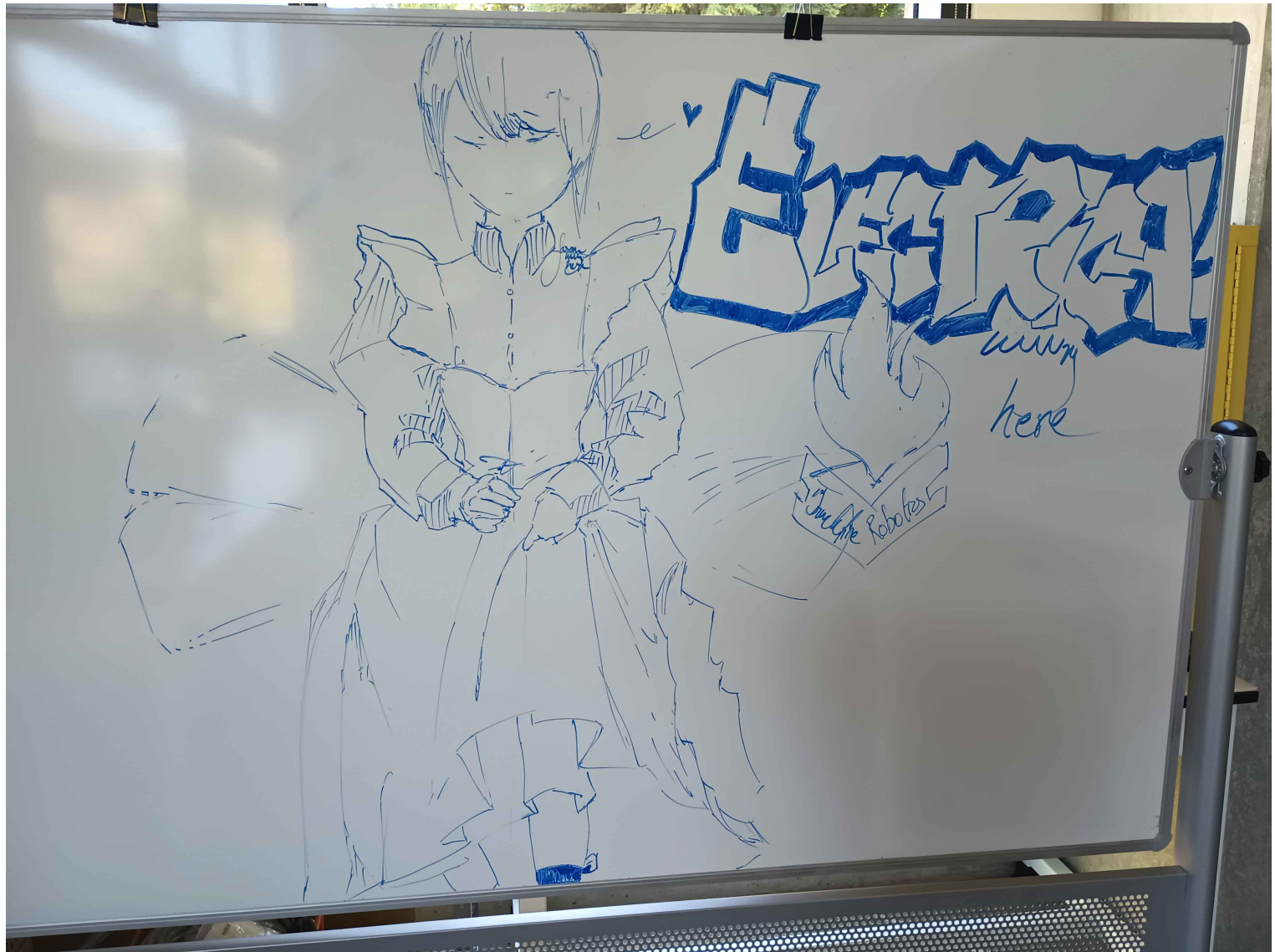
$k$  = Boltzmann's constant ( $1.38 \times 10^{-23}$ )

$T$  = Junction Temperature in Kelvins

## Bibliography

### Cited:

- Lab 1 Manual
- Sedra, Adel, and Kenneth Smith. Microelectronic Circuits. S.L., Oxford Univ Press Us, 2019.



(a) Keep believing in yourself.